



Atty. Dkt. No. 039262-0149

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Tadahiro OHMI, et al.
Title: ELECTRON BEAM EXPOSURE APPARATUS AND
EXPOSURE METHOD
Appl. No.: 10/567,828
Filing Date: 4/28/2006
Examiner: Christopher G. Young
Art Unit: 1795
Confirmation No.: 2084

AMENDMENT AND REPLY UNDER 37 C.F.R. 1.111

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This communication is responsive to the Non-Final Office Action dated March 11, 2009, concerning the above-referenced patent application.

Applicants have enclosed with this amendment a Petition for Extension of Time for three months to make this response timely.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this document.

Remarks/Arguments begin on page 5 of this document.

Please amend the application as follows: